

Amendments to the Specification

Please replace paragraph [0060] with the following amended paragraph:

[0060] The CeO₂ layer should be at least 50 nm in thickness, but for adequate orientation to be obtained, at least 100 nm is preferable, and at least 500 nm is even better. However, if the thickness exceeds 5000~~500~~ nm, crystal orientation will suffer. Therefore, a thickness of 5000~~500~~ nm or less is preferred.

<Oxide Superconducting Film>